

	Type	Hits	Search Text
1	BRS	11	US-6130517-\$.DID. OR US-5926681-\$.DID. OR US-5892117-\$.DID. OR US-5874820-\$.DID. OR US-5835275-\$.DID. OR US-5689377-\$.DID. OR US-5668672-\$.DID. OR US-5623853-\$.DID. OR US-5528118-\$.DID. OR US-4952858-\$.DID. OR US-4506204-\$.DID.
2	BRS	58373	(mask or reticle or substrate or wafer) with (stage or table)
3	BRS	201296	(position\$3 or align\$4 or move or moved or moving or moves or rotat\$3 or yaw\$3 or pitch\$3) with (stage or table)
4	BRS	1	960584.ap.
5	BRS	19310	((mask or reticle or substrate or wafer) with (stage or table)) and ((position\$3 or align\$4 or move or moved or moving or moves or rotat\$3 or yaw\$3 or pitch\$3) with (stage or table))
6	BRS	5774	(flexible or spring or bellow) and (((mask or reticle or substrate or wafer) with (stage or table)) and ((position\$3 or align\$4 or move or moved or moving or moves or rotat\$3 or yaw\$3 or pitch\$3) with (stage or table)))
7	BRS	482	(degree near2 freedom) and ((flexible or spring or bellow) and (((mask or reticle or substrate or wafer) with (stage or table)) and ((position\$3 or align\$4 or move or moved or moving or moves or rotat\$3 or yaw\$3 or pitch\$3) with (stage or table))))
8	BRS	118	((degree near2 freedom) and ((flexible or spring or bellow) and (((mask or reticle or substrate or wafer) with (stage or table)) and ((position\$3 or align\$4 or move or moved or moving or moves or rotat\$3 or yaw\$3 or pitch\$3) with (stage or table)))) and (355/\$.ccls. or 318/\$.ccls.))

	Type	Hits	Search Text
9	BRS	176848	(position\$3 or align\$4 or move or moved or moving or moves) with (stage or table)
10	BRS	59112	(rotat\$3 or yaw\$3 or pitch\$3) with (stage or table)
11	BRS	4850	((position\$3 or align\$4 or move or moved or moving or moves) with (stage or table)) and ((rotat\$3 or yaw\$3 or pitch\$3) with (stage or table)) and ((mask or reticle or substrate or wafer) with (stage or table))
12	BRS	1697	(flexible or spring or bellow) and (((position\$3 or align\$4 or move or moved or moving or moves) with (stage or table)) and ((rotat\$3 or yaw\$3 or pitch\$3) with (stage or table)) and ((mask or reticle or substrate or wafer) with (stage or table)))
13	BRS	209	(degree near2 freedom) and ((flexible or spring or bellow) and (((position\$3 or align\$4 or move or moved or moving or moves) with (stage or table)) and ((rotat\$3 or yaw\$3 or pitch\$3) with (stage or table)) and ((mask or reticle or substrate or wafer) with (stage or table))))
14	BRS	91	((degree near2 freedom) and ((flexible or spring or bellow) and (((position\$3 or align\$4 or move or moved or moving or moves) with (stage or table)) and ((rotat\$3 or yaw\$3 or pitch\$3) with (stage or table)) and ((mask or reticle or substrate or wafer) with (stage or table))))) and (355/\$.ccls. or 318/\$.ccls. or 310/\$.ccls.)

